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Information Disclosure Statement

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U. S. PATENT DOCUMENTS

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Title: Chemical Vapor Deposition of Diamond Coatings on Hard Substrates

OTHER DOCUMENTS (Including Author, Title, Date, Place of Publication)

a. K.K. Lai and H.H. Lamb. Tungsten Chemical Vapor Deposition Using Tungsten Hexacarbonyl: Microstructure of As-Deposited and Annealed Films. Thin Solid Films, Vol. 370, No. 1-2, pgs. 114-121 (2000).

b. _____

c. _____

d. _____

e. _____

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EXAMINER: Initial citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

Substitute Disclosure Form (PTO-1449)

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